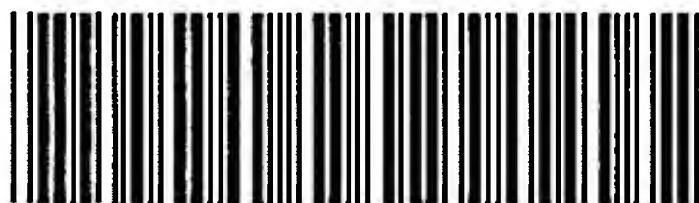


Search Notes

Application No.

10/604,895

Examiner

Stephen W. Smoot

Applicant(s)

WU, CHING-HSIU

Art Unit

2813

SEARCHED

Class	Subclass	Date	Examiner
438	4	8/7/2004	SWS
438	14	8/7/2004	SWS
438	623	8/7/2004	SWS
438	763	8/7/2004	SWS
438	780	8/7/2004	SWS
438	782	8/7/2004	SWS
438	788	8/7/2004	SWS

INTERFERENCE SEARCHED

Class	Subclass	Date	Examiner

**SEARCH NOTES
(INCLUDING SEARCH STRATEGY)**

	DATE	EXMR
Key Words: Spin-on Material - Glass, SOG, Resist, Photoresist, MSQ, HSQ, Silsesquioxane;	8/7/2004	<i>S.W.S.</i> SWS
Clean, Wash, Rinse - Scrub; Interconnect - Wiring, Trace, Line, Conductor, Metal, Copper, Aluminum;	8/7/2004	<i>S.W.S.</i> SWS
Etch - Dry, Wet, BHF, Ashing, Stripping.	8/7/2004	<i>S.W.S.</i> SWS
Search Tools - EAST (attached): USPAT; US PG PUBS; Derwent; EPO; JPO; IBM TDB	8/7/2004	<i>S.W.S.</i> SWS